



**RAJARATA UNIVERSITY OF SRI LANKA  
FACULTY OF APPLIED SCIENCES**

B.Sc. (Joint Major) Degree in Chemistry & Physics

Fourth Year - Semester I Examination – October/November 2015

**PHY 4209 – PHYSICS OF ELECTRONIC DEVICES**

Answer all four questions

Time: Two hours

**Use of a non programmable calculator is permitted.**

**Unless otherwise specified, all the symbols have their usual meaning.**

Some fundamental constants;

Electron rest mass  $m_e = m_0 = 9.1 \times 10^{-31} \text{ kg}$

Elementary charge  $e = 1.6 \times 10^{-19} \text{ C}$

Electron volt  $eV = 1.6 \times 10^{-19} \text{ J}$

Permittivity of free space  $\epsilon_0 = 8.85 \times 10^{-12} \text{ C}^2 \text{ N}^{-1} \text{ m}^{-2}$

Boltzmann Constant  $k = 1.38 \times 10^{-23} \text{ J K}^{-1}$

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- (1) (a) i. Derive the expression for the position of the Fermi level relative to the center of the band gap as a function of temperature in an intrinsic semiconductor. [10 marks]

- ii. Calculate the displacement of  $E_F$  from the center of the gap in *Si* at 300 K assuming  $m_e^* = 1.1m_e$  and  $m_h^* = 0.56m_e$ . ( $kT \sim 0.026 \text{ eV}$  at 300 K) [06 marks]

- (b) The electron and hole mobilities in a *Si* sample are  $0.135$  and  $0.048 \text{ m}^2 \text{ V}^{-1} \text{ s}^{-1}$  respectively. Determine the conductivity of intrinsic *Si* at 300 K, if the intrinsic carrier concentration is  $1.5 \times 10^{16} \text{ atoms/m}^3$ . The sample is then doped with  $10^{23}$  phosphorus  $\text{atoms/m}^3$ . Determine the equilibrium hole concentration, conductivity and position of the Fermi level relative to the intrinsic level.

Hint:  $E_F - E_i = kT \ln \left( \frac{n}{n_i} \right)$

[09 marks]

**Contd.**



- (2) (a) Show that the curvature of the energy band in which the particle (electron or hole) moves is inversely proportional to the mass of the particle. [08 marks]

- (b) A hypothetical energy band can be fitted approximately to the expression  $E(k) = E_0[1 - \exp(-2a^2k^2)]$  where  $a$  is the lattice constant of the crystal.

Calculate

- i the effective mass at  $k = 0$ , [06 marks]
- ii the value of  $k$  for maximum electron velocity, and [05 marks]
- iii the effective mass at the edge of the Brillouin zone. [06 marks]

- (3) (a) *In* has a valency of III and is a metal. *Sb* is also a metal and has a valency of V. The compound *InSb* is a semiconductor with each atom bonding to four neighbors, just as in *Si*. Explain how this is possible and why *InSb* is a semiconductor and not just a metal alloy. [10 marks]

- (b) If there are no acceptors and  $N_d$  donors per unit volume are present in a doped semiconductor at very low temperature, then the density of electrons in the conduction band is  $n(T) = N_d e^{-\Delta E / 2kT}$  where  $\Delta E$  is the binding energy of the donor level relative to the edge of the conduction band with the assumption of  $\Delta E \gg kT$ . Explain why then the low temperature behavior of  $n(T)$  changes to  $n(T) = (N_d - N_a) e^{-\Delta E / kT}$ , when there are  $N_d$  donors and  $N_a$  acceptors per unit volume with  $N_a < N_d$ . [15 marks]

- (4) Write short notes on the following.

- (a) The impact of heavy doping on the density of states. [09 marks]
- (b) Kronig-Penny model [08 marks]
- (c) Advantages of using quantum wells in optoelectronic applications. [08 marks]

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